

## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicants: HAGIWARA, et al.

Serial No.: 09/482,859 (CPA)

Filed: December 19, 2000  
January 14, 2000 (prior)

For: DEC 19 2000 PHOTORESISTIVE RESIN COMPOSITION

Group: 1752

Examiner: J. Chu



  
 1/11/01

PRELIMINARY AMENDMENTAssistant Commissioner for Patents  
Washington, D.C. 20231

December 19, 2000

Sir:

In light of the Office Action mailed September 22, 2000, in connection with the above-identified application, and concurrently with the filing of a Continued Prosecution Application (CPA) Request Transmittal filed in connection with application Serial No. 09/482,859, please amend the above-identified application as follows:

IN THE SPECIFICATION

Please delete the present title, and substitute therefor:

--PHOTORESISTIVE RESIN COMPOSITION--.

IN THE CLAIMS

Please cancel claims 1-9 and 15-19 without prejudice or disclaimer, and amend the claims remaining in the application as follows:

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 1/11/01  
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